

#### Technology Metals | Advanced Ceramics Pushing Tantalum capacitors to the limit: A powder

## manufacturers view to 300 V anodizations and beyond

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## High Voltage Market Trends: Focus High Reliability

Increasing demand for HV applications!





**Aviation** 



Aerospace



**Transportation and** 

Railroad



urce: Deutsch Bahn, Wikipedia

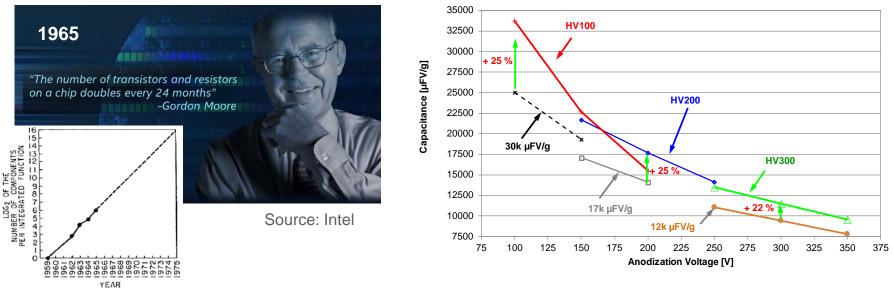
Automotive



Defense



## Moore's Law – Trends for High Voltage Applications



Also continuous performance improvement for Ta capacitors!

Major trends for the recent years:

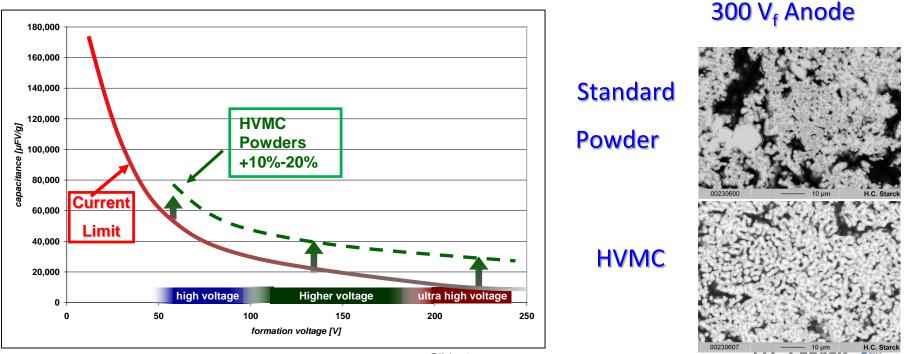
- 1. Increase capacitance at a given voltage e.g.  $150 V_{f}$
- 2. Increase forming voltage above 300 V<sub>f</sub>  $\rightarrow$  More energy!

High Voltage Medium Capacitance = HVMC



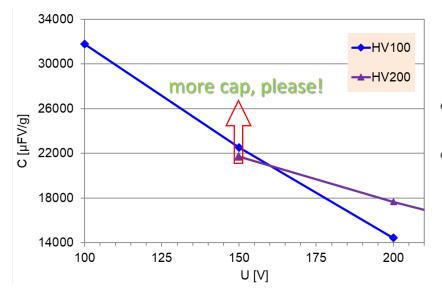
# What Makes HVMC Powder so Unique

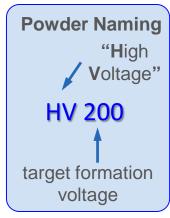
- 1. Superior microstructural homogeneity of pores and particles
- 2. Pore and primary particle structure can be tailored to application needs
  - $\rightarrow$  Primary particle size can be varied from 0.3  $\mu$ m 3  $\mu$ m
  - ➔ Pore size distribution can be tailored within a specific powder charge category
- 3. Provides higher purity than Na powder (Fe, Cr, Ni < 10 ppm, and K, Na <1ppm)



# 1. Trend: How to Provide More Capacitance?

- New capacitors for  $U_f \sim 150 V_f$  highly requested
- Task: Provide more cap than existing HVMC powders (HV100/HV200)





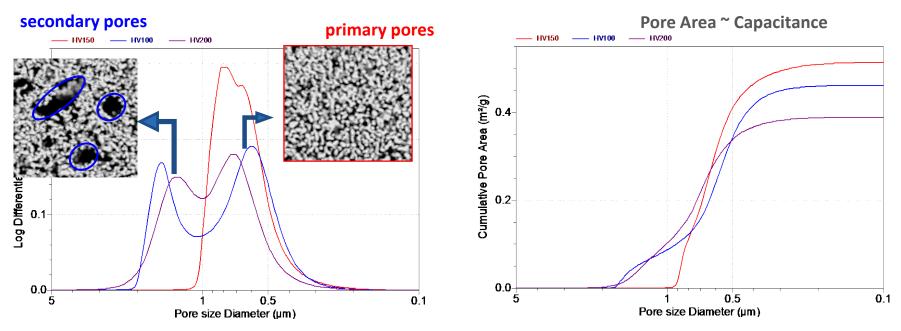
- HV100: pores too small → worse ESR
- HV200: better pores but lower cap

#### Develop new powder by improving particle and pores size distribution!



## 1. Trend: How to Provide More Capacitance?

- Production parameters optimized according to microstructure!
- Anode pore size + primary particle distribution was improved → nearly monomodal

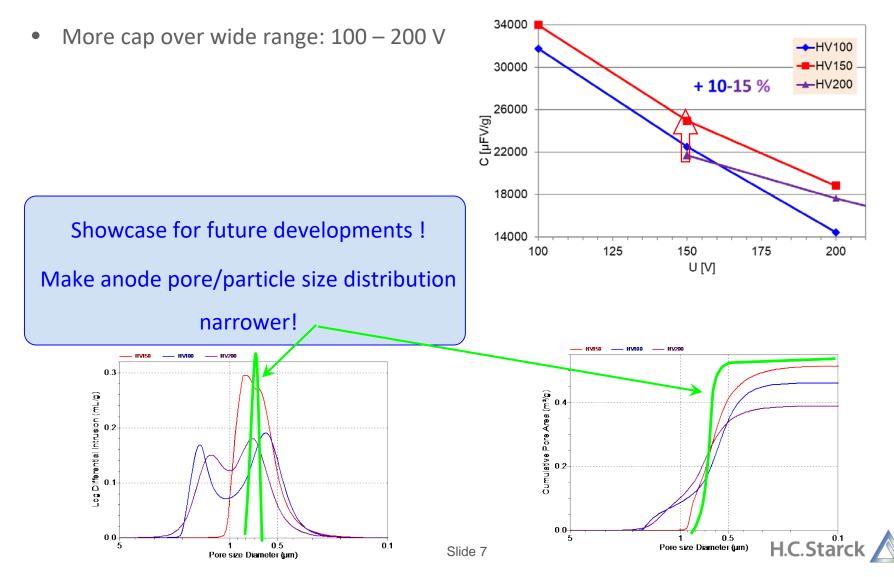


#### Anode Pore Size Distribution (PD 6,0 g/cm<sup>3</sup>, ~10 % shrinkage)



## Structure Impact on Capacitance

• New powder provides 10 -15 % more capacitance than other HVMC powders



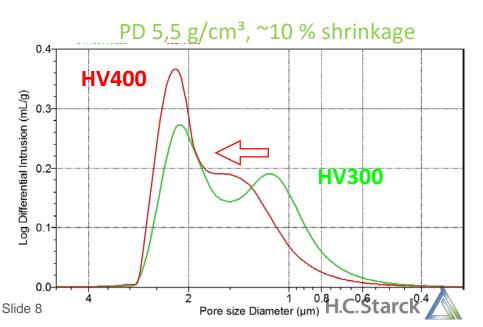
# 2. Trend: Increase Forming Voltage

- Currently, HV300 provides highest energy density @ 250-300 V
- Task: Provide more energy W by increased forming voltage U

$$W = C \int_0^U u \, \mathrm{d}u = \frac{C U^2}{2}$$

- Powder microstructure has to be adapted:
- 1. Increase primary particle size
- 2. Increase pore size
- 3. Improve pore distribution

New HV400 developed





Anode Pore Size Distribution

## New HV400 - Properties

- Increased capacitance at 400 V<sub>f</sub>: + 20 %
- Open pore structure, no macroscopic defects observed

Cross section of HV400 @ 400 V<sub>f</sub> 14000 13000 12000 Cap [µFV/g] 10000 Cap 9000 8000 7000 225 250 325 275 300 Uf [V] 10 µm H.C. Starck 258008 3 µm

Could work until 450 V BUT: Increase of Leakage >10 nA/µC for higher voltages

Standard anodization process still sufficient?



375

350

HV300

+ 20 %

400

425

Capacitance

# 3. Impact of Anodization

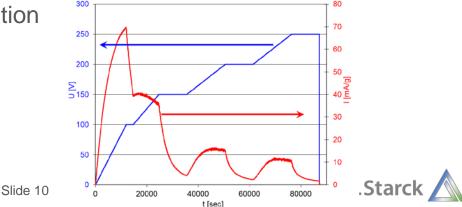
- Anodization has an big impact on capacitance and LC
- Aqueous electrolyte systems not appropriate for  $U_f > 200 V_f$
- Additives are used to improve breakdown stability and LC:
  - Ethylene glycol, phosphoric, boric and citric aid

Task: Separate impact of anodization from powder modification

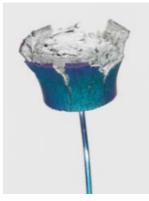
Experimental part

- HV200 large cylindrical anodes (Ø 8,0 mm, 2,2 g, PD 6.0, 10 % shr.)
- Forming U<sub>f</sub>: 150 250 Vf at 60°C, water-glycol bath (2:3), 900  $\mu$ S/cm by H<sub>3</sub>PO<sub>4</sub>
- Forming with "constant rate" anodization

### ➔ Analyse anodes after forming

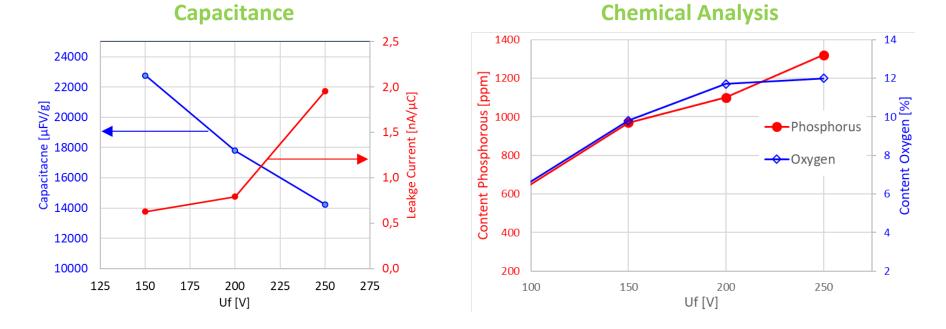






# 3. Impact of Anodization: Results





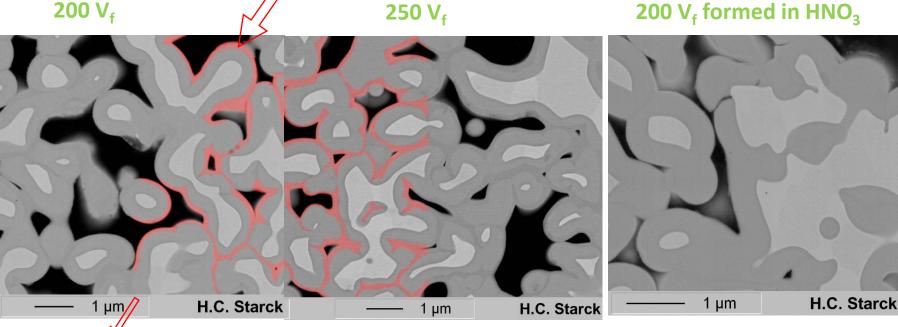
- Increase of oxygen by forming
- Strong incorporation of phosphorus, probably as PO<sub>4</sub><sup>3-</sup>
- Strong increase of LC at 250 V



## **Incorporation of Phosphorous**

outer oxide layer: incorporation of PO<sub>4</sub><sup>3-</sup> 

 $200 V_{f}$ 



370 nm oxide

1100 ppm P → 3370 ppm PO<sub>4</sub><sup>3 -</sup> = 0,53 %

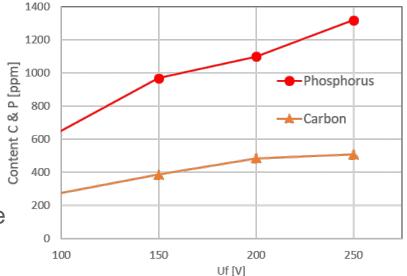
~85 nm outer  $PO_{4}^{3-}$  rich layer 117000 ppm O → 637280 Ta<sub>2</sub>O<sub>5</sub>

P is only found at the outer layer! Phosphate content is increased to 2,3 wt-.% = 9,9 mol%



## Incorporation of Carbon

- High carbon content found: 390 510 ppm
- Unclear how it is incorporated
- From decomposition of glycol?
- Powder with >60 ppm C is difficult to anodize for high voltage powder

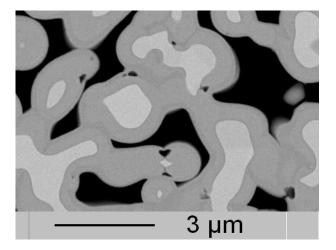


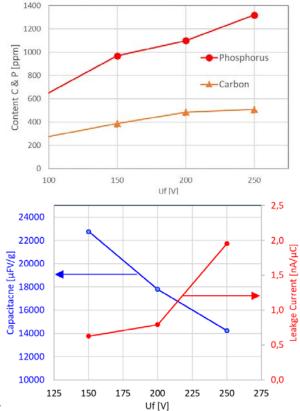
→ Not only carbon amount also how it is introduced has an big impact!



# Effect of Incorporations

#### 250 V<sub>f</sub>





Defects can be found at the interface outer/inner layer

- → caused by PO43-?
- → Caused by gas formed during anodization (oxygen?)
- → Caused by decomposed electrolyte (carbon)?

HV anodization has to be adapted!



## Summary

Powders Developments for more capacitance/energy

- New HV150 with increased capacitance by improve microstructure
- New HV400 available than can be formed to 400 V

Anodization

- Forming to 400 V is challenging
- Strong incorporation of P and C found
- Is Phosphorous really beneficial?

Search for perfect electrolyte has began. "Wish list":

- Stable until 450 500 V, no decomposition
- No or limited incorporation of foreign ions
- Good heat conductivity





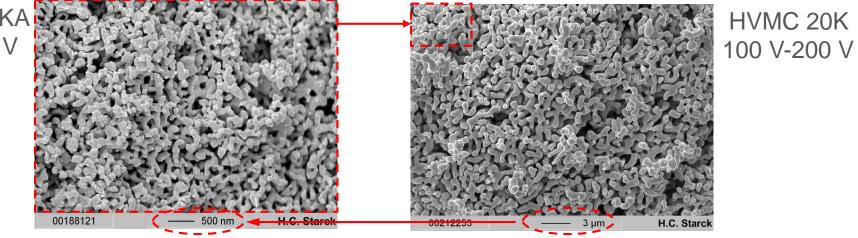
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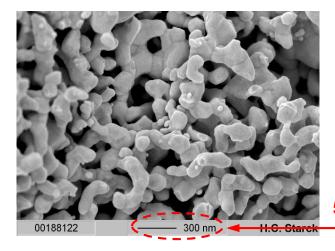
## Microstructure of HVMC Anodes

#### Increasing the dimensions but keep the structure homogeneous!





#### 5 x higher magnification



5 x higher

